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Suzuki et al.

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(54) **LINER FOR PLASMA PROCESSING APPARATUS**

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156/345.46; 205/50; 216/67, 69, 70; 219/121.36,
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See application file for complete search history.

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(57) **CLAIM**

The ornamental design for a liner for plasma processing apparatus, as shown and described.

DESCRIPTION

FIG. 1 is a front view of a liner for plasma processing apparatus showing our new design;
FIG. 2 is a rear view thereof;
FIG. 3 is a top plan view thereof;
FIG. 4 is a bottom plan view thereof;
FIG. 5 is a right side view thereof;
FIG. 6 is a left side view thereof;
FIG. 7 is a sectional view taken along line 7-7 of FIG. 1 thereof;
FIG. 8 is a sectional view taken along line 8-8 of FIG. 1 thereof; and,
FIG. 9 is a perspective view thereof.

1 Claim, 3 Drawing Sheets



FIG.1

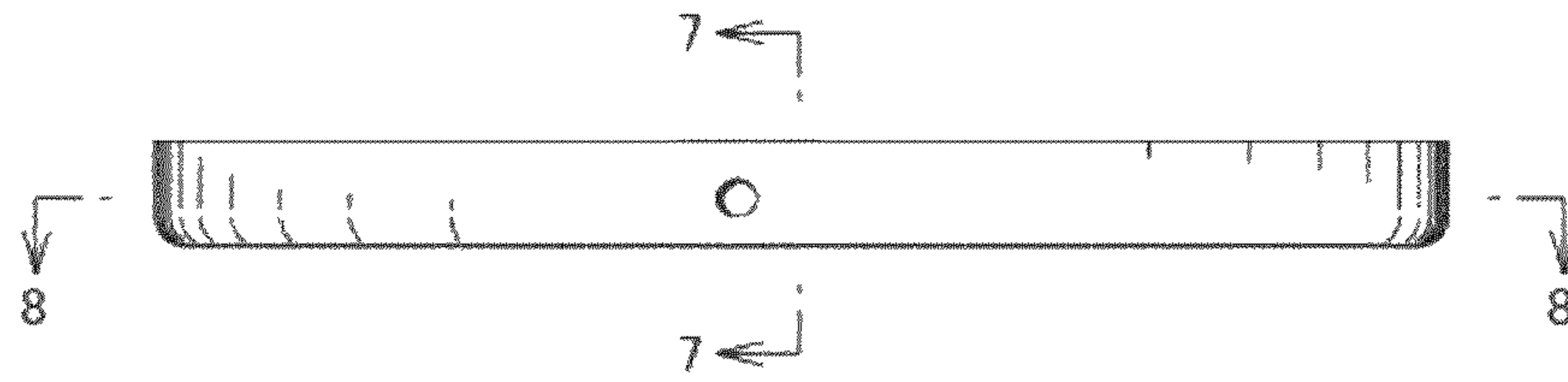


FIG.2



FIG.3

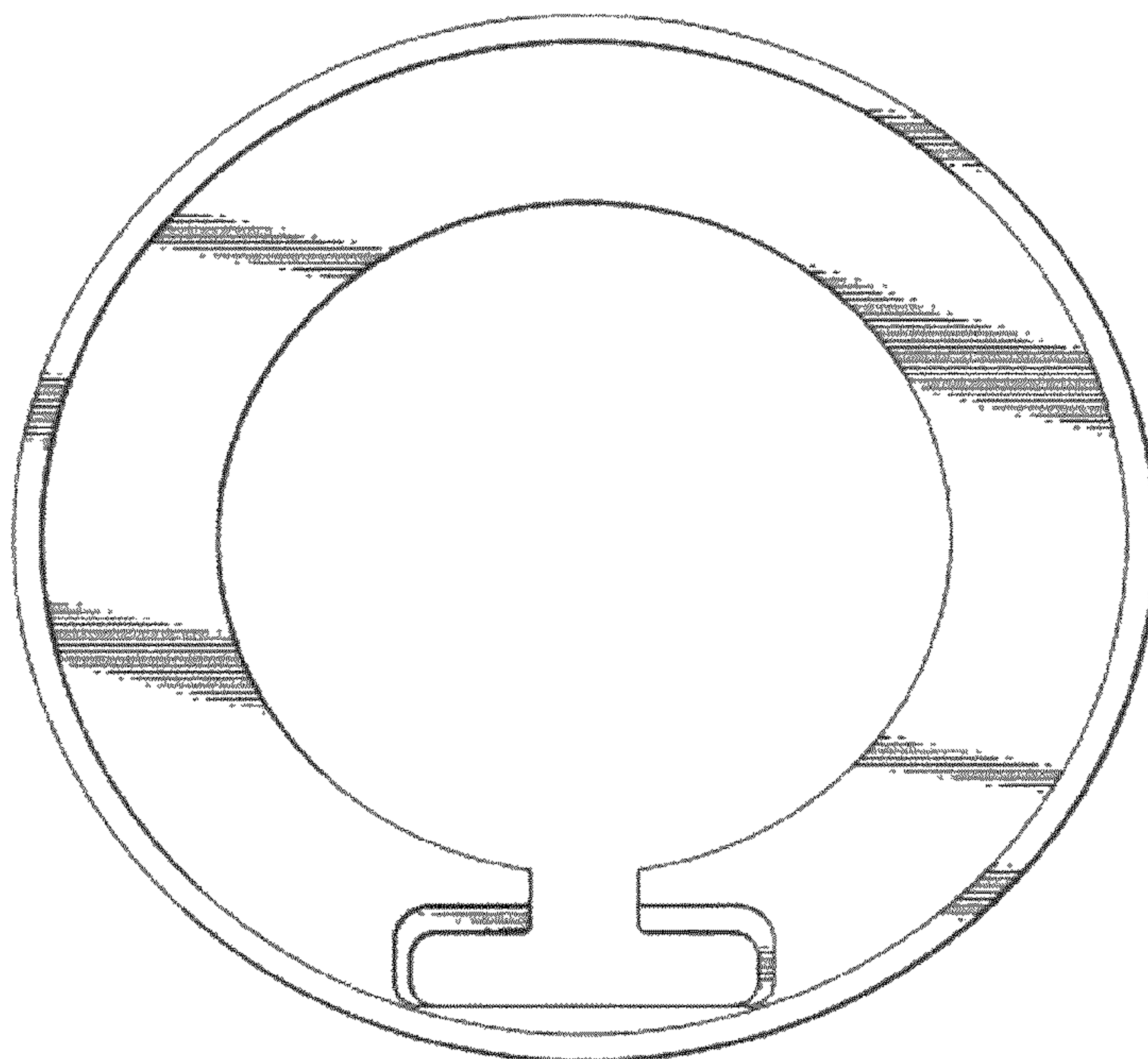


FIG.4

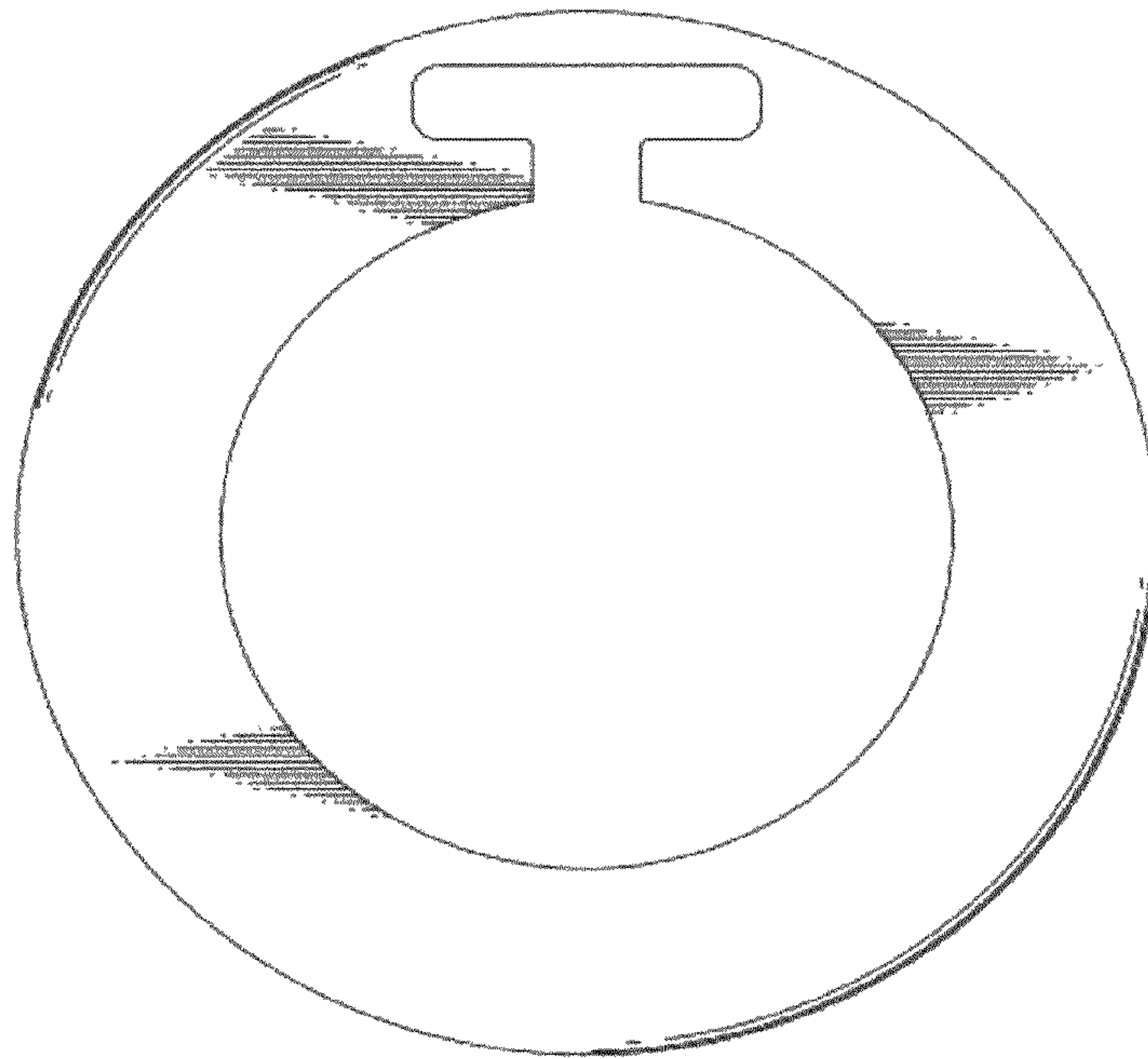


FIG.5



FIG.6



FIG.7

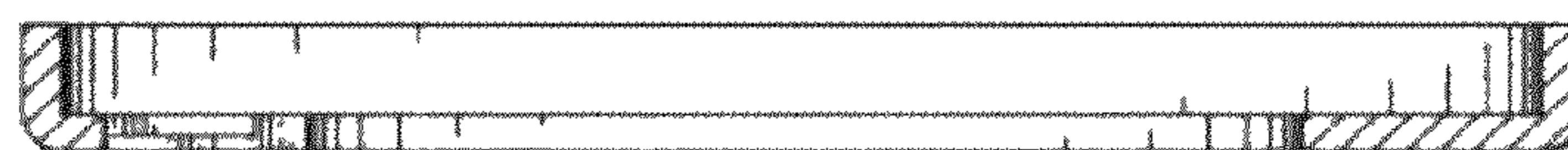


FIG.8

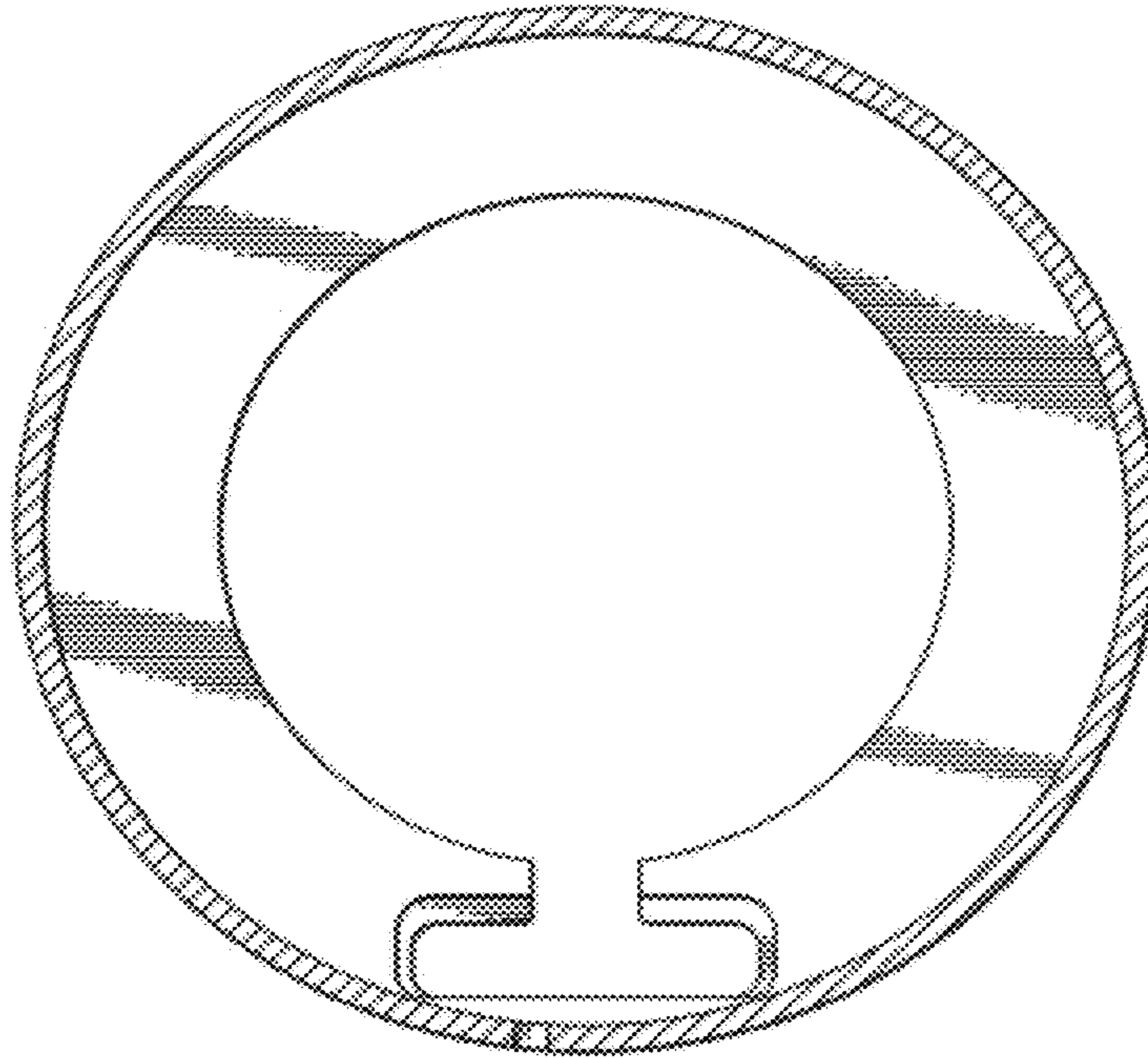


FIG.9

